Notice of Allowability	Application No.	Applicant(s)	Applicant(s)	
	10/008,253	LORUSSO ET AL.		
	Examiner	Art Unit		
	Paul Gurzo	2881		
The MAILING DATE of this communication appears on the cover sheet with the correspondence address-All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308. 1. This communication is responsive to 8/12/03.				
2. ☑ The allowed claim(s) is/are <u>1-20 and 22</u> .				
 3.				
1. Certified copies of the priority documents have been received.				
2. Certified copies of the priority documents have been received in Application No				
3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).				
* Certified copies not received: 5. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).				
(a) ☐ The translation of the foreign language provisional application has been received.				
6. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.				
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 7. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.				
 8. CORRECTED DRAWINGS must be submitted. (a) including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached 1) hereto or 2) to Paper No (b) including changes required by the proposed drawing correction filed, which has been approved by the Examiner. (c) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No 				
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet.				
9. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.				
Attachment(s)				
 Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449), Paper No Examiner's Comment Regarding Requirement for Deposit of Biological Material 	4 <u></u> Interv 6 Exam	e of Informal Patent Application (Fiew Summary (PTO-413), Paper iner's Amendment/Comment iner's Statement of Reasons for A	No	

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DETAILED ACTION

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Allowable Subject Matter

Claims 1-20 and 22 are allowed.

The following is an examiner's statement of reasons for allowance: As the claimed invention was read in light of the specification, the prior art of record fails to disclose or render obvious a method for inspecting a specimen by detecting electrons that scatter from the specimen comprising scanning and directing an electron beam to irradiate a spot on the specimen, the electron beam causing the electrons to scatter from the irradiated spot on the specimen, setting a high pass filter at a first voltage level, the first voltage level being predetermined, detecting the scattered electrons with the high pass filter that is set at the first voltage level, the high pass filter detecting a first electron intensity level of the scattered electrons, setting the high pass filter at a second voltage level, the second voltage level being predetermined, detecting the scattered electrons with the high pass filter that is set at the second voltage level, the high pass filter detecting a second electron intensity level of the scattered electrons, determining a differential electron intensity level, which is the difference between the first electron intensity level and the second electron intensity level, whereby the differential electron intensity level is the electron intensity level in an energy window between the first and second voltage level, and repeating each of the setting, detecting and determining operations to obtain additional differential electron intensity levels for successively irradiated spots along the scanned specimen, whereby the plurality of determined differential electron intensity levels provide inspection information about the specimen.

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The closest prior art, Iwasaki and Lo et al., teach a method for inspecting a specimen comprising scanning and directing an electron beam, setting a high pass filter at a first predetermined level, setting a second voltage, and determining intensity levels. However, they do not teach the second voltage level being predetermined. Rather, it is changed to find the potential of the grid for intensity determination. Also, they teach discriminating secondary electrons based on energy levels, but they do not determine a differential electron intensity level by calculating the difference between the first and second electron intensity levels.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Paul Gurzo whose telephone number is (703) 306-0532. The examiner can normally be reached on M-Thurs. 7:30 - 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Lee can be reached on (703) 308-4116. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9318 for regular communications and (703) 872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

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PMG

August 28, 2003

SUPERVISION EXTENT EXAMINER TECHNOLOGY CENTER 2000